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From a ToF-SIMS study on glass corrosion to self-healing surfaces

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IMWS/CAM (Center for Applied Microstructure Diagnostics)



Who we are



We address the smallest dimension - with microstructurebased diagnostics and technology development for innovative materials, components and systems.



We develop solutions for functionality, reliability, safety, durability, sustainability and accelerated development of materials.



We increase the material efficiency and cost-effectiveness of materials and systems, thus helping to conserve resources.



Materials Insights

From the microstructural material and component characteristics, statements can be made about the properties in the application case.



Methodically Oriented Portfolio Institute for Microstructure Diagnostics & Microstructure Design





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Business Unit «Optical Materials and Technologies»

Service Offering Consists of Three Pillars





Corrosion Studies

Glass as a Material



- Earliest traces of glass made by humans: > 5000 years
 Optical properties in visible range
- Great stability over time, but sensitive to stress
- Glass corrosion: depending on environmental conditions
 Industrial approach to increase durability:
 - increased hardness, especially for edges and corners
 - chemical resistance



Corrosion Studies

Glass Surface Functionalization



- Hardening of the glass surface:
 - by ion exchange processes
 - by tempering (heating and rapid cooling of the surface)
 - Improving chemical stability and optical properties:
 - deposition of (multi-layered) coatings





Corrosion Studies

Glass Corrosion

- General knowledge: corrosion processes of inorganic glasses are well understood.
- Ion exchange processes at the glass surface lead to the formation of a gel-like layer, influencing the mechanical and optical properties of the glass.
- Processes are accelerated in combination with water or humidity in the environment.
- The glass stoichiometry influences the corrosion behavior
- But: most of this knowledge is phenomenological.
- The microstructural mechanisms are an actual research topic, and the improvements in surface and microstructural analysis promise further insights.





How it Started ToF-SIMS Corrosion Studies



85 SiO₂ - 15 Rb₂O glass made at 1600 °C

- Innovent and Fraunhofer IMWS wanted to improve the general knowledge about glass corrosion, in order to mitigate the process.
- Theoretical work at Innovent (Dr. Detlef Stock) indicated that superficial redistribution of elements/bonds might be key.
- IMWS suggested to have a look into the surface-near composition of a glass using time-of-flight SIMS.
- Due to its omnipresence on surfaces and very high mobility of sodium, it was decided to have a look at a quasi-binary, alkali silicate model glass x SiO₂ / (100-x) Rb₂O (x=90, 85, and 80, mol%).
- A "thirsty glass" was produced by bubbling with dried Ar.
- ToF-SIMS proved CO_2 and water uptake by the x SiO₂ / (100-x) Rb₂O glasses.



How it Started STEM-EDX Corrosion Studies



HV: 300kV

600 nm

HV: 300kV

TEM cross section also revealed some interface a few microns below the surface.



600 nm

HV: 300kV

600 nm

How it Started White Light Interferometry



Wight light interferometry was used to measure the depth of the ToF-SIMS crater (crater depth vs. sputter time)
 The crater did not have a depth, but a *height* -> problem of different refractive indices?

Mechanical profilometry and WLI after metal coating of the surface proved the effect.

How it started

Cross section



Optical cross section of the surface skin and the recovered volume of a superficially harmed (ToF-SIMS depth profiling down to a depth of ca. 3 µm) 80 SiO₂ / 20 Rb₂O glass



How it Started

Self Healing Glass Surface – possible explanation

- Rubidium silicate glasses are known to be highly hygroscopic.
- Therefore, contact with humidity was controlled in many ways:
 - Dry (bubbling with dried Argon) and standard melting of glass
 - Preparation of surfaces and cross-sections w and w/o water
 - Storage in exicators
- IR spectroscopy is a tool to measure the water content in glass.
- Glasses that are molten dry have the tendency to take up water afterwards.
- Upon this water uptake, the glass forms a skin that acts as a barrier against continued water uptake.
- Injuring this skin brings buried glass (that did not take up water so far) in contact with water vapor, resulting in self healing.
- The effect is particularly pronounced for SiO₂ Rb₂O glasses, but likely to occur in other alkali silicate glasses (in a lesser amount) as well.



How it Started Proof of Principle



- Not just dry-molten 80 SiO₂ 20 Rb₂O glass is prone to superficial changes after hurting the glass skin.
- Also less "exotic" glass compositions, like 75 SiO₂ / 25 K₂O glass, show self-healing (crater 1&2).
- At depth profiling position 4, oxygen ions were used to sputter a ca. 140 nm deep excavation. The depth of the excavation exactly corresponds to the thickness of the glass skin after gentle corrosion.
- Within 8 days, this sputter crater did not show degradation nor healing (K depletion, water take-up etc.).



How it Started Proof of Principle





Initial depth profiling of craters #2 & #4 compared to signal after 2 weeks: complete removal of surface layer leads to a pronounced water and CO2 uptake.



And Now? Variation of Material Systems





- The properties of a glass are dominated by the stoichiometry of its oxide components. However, even at temperatures above 1000 °C, water is incorporated into the structure (OH-), typically between 300 ppm and 400 ppm.
- "Thirsty" glasses can be produced by bubbling (<10 ppm) with dried Ar.</p>
- As Rb₂O-SiO₂ is quite exotic, other alkali-containing glasses have to be tested (Na, K).
- Variation of Rb₂O (or Na, K) content and water content.
- Necessary: characterization of produced glasses (DSC, IR...).



And Now? Variation of Damage









- Ion species (O, Cs, Ar, Ga, Xe, Kr), energy and sputter depth.
- Laser damage (ablation or local melting).
- mechanical scratching or tribological testing.

Mechanism of the formation of new material to form a flat (healing) or convex (structuring) surface?





- A very "thirsty" hygroscopic glass was produced at IMWS (Rb₂O-SiO₂), showing an unknown and unexplained behavior after the surface was "damaged" by ToF-SIMS depth profiling.
- The crater with a depth of a few μ m "healed" itself in just a few days.
- The effect could be reproduced using Ar (ToF-SIMS) and Xe (plasma FIB) ions.
- A local removal of material leads to the formation or growth of new glass at the surface, not limited by the initial surface.
- Microstructural analysis (STEM-EDX) do not show measurable differences in the glass stoichiometry of the healed area, compared to undamaged regions.
- The stress induced by preparation and analysis of the samples did not show significant differences between the new grown glass and the bulk material, indicating comparable durability.
- The effect could successfully be translated to another hygroscopic alkali glass system (K₂O-SiO₂).



Outlook

FhG-internal Discover project @IMWS.

- The effect is particularly pronounced for SiO2 Rb2O glasses, but likely to occur in other alkali silicate glasses (in a lesser amount) and in SiO2-Rb2O glasses with lower R2O-content as well.
- Changing the stoichiometry influences the growth of the healed surface. Thus, healing of scratches without "overgrowing" should be possible (smarter self healing).
- Optically active structures can be thought of by defined injury of a suitable glass. Upscaling?
- Role of CO2 to be clarified.
- SiO2 Rb2O glass coating might be an unconventional way to protect arbitrary glass surfaces from breaking (instead of imposing strain by ion exchange).



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Equipment Microstructure Diagnostics

Preparation





Grinding Polishing Embedding Sawing Laser machining Coating SEM (4x) SEM/FIB (7x)



EDXS WDXS EBSD EBAC & EBIC Ga+- & Xe+-FIB Nano probing S/TEM (3x)



EDXS (0,8 & 2 sr) EELS Nano diffraction aberration corrected 60 – 300 kV "single e⁻ detection" Depth profiling Gas cluster ion source Cryo- & heating option Polymer analytics

ToF-SIMS (2x)

XPS



Chemical composition Bonding stages



Optical Coatings Typical Failures and Analysis Techniques: ToF-SIMS

intensity 0'01

0.001

<u>e</u>



- Time-of-flight secondary ion mass spectrometry: elemental and molecular composition of a surface with detection sensitivity in ppm-ppb region.
- Depth profiling via combination with different sputtering ion beams.
- Lateral resolution < 100 nm, depth resolution ~ nm.
- Detection of (interface) contaminations, interdiffusion and spurious elements.
- GCIB (organics) and cryo options available.





Depth Profiling, 0 – 400 s (≈ 820 nm) Pos. 1 (pristine) = Reference vs. Pos. 1 (13 days later) vs. Pos. 4 (flat excavation, 13 days later)



Alle signals shown here and herafter are normalised to the total intensity.



Depth Profiling, 0 – 400 s (≈ 820 nm) Pos. 1 (pristine) = Reference vs. Pos. 1 (13 days later) vs. Pos. 4 (flat excavation, 13 days later)



- Superficially, the smooth surface of position 4 features the highest silicon intensity.
- The latter steeply drops within the first ~ 20 nm below the surface in a constant level



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Depth Profiling, 0 – 1200 nm Pos. 2 (pristine) = Reference vs. Pos. 2 (13 days later) vs. Pos. 4 (flat excavation, 13 days later)



- In the pristine surface, the H signal is enriched within the topmost 10 nm, goes into a plateau going 150 to 200 nm below the surface and approaches than a one order of magnitude lower bulk level
- After ageing, the freshly formed surface features a much increase H content





Depth Profiling, 0 – 1200 nm Pos. 2 (pristine) = Reference vs. Pos. 2 (13 days later) vs. Pos. 4 (flat excavation, 13 days later)



- Incorporation of CO₂ after removal of 1,6 µm by Cs⁺ sputtering
- Much reduced CO₂ incorporation after 140 nm O²⁺ sputtering.



